

In situ growth of Te-doped Cs₂SnCl₆ scintillator composite films for X-ray imaging

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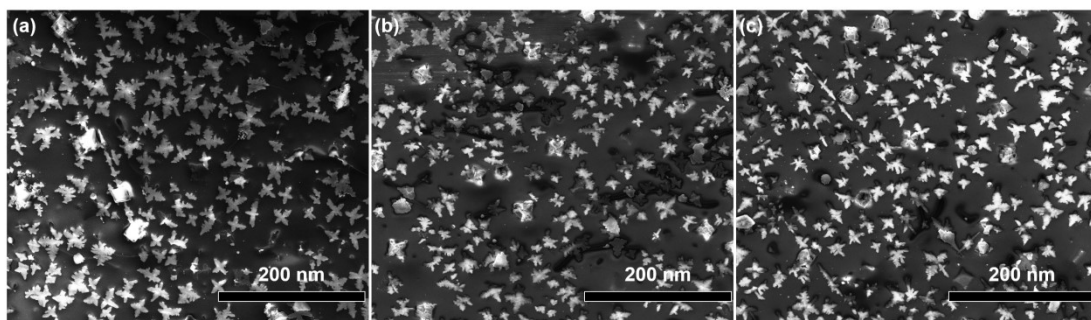


Figure S1. SEM images of a) $\text{Cs}_2\text{SnCl}_6\text{:Te}$ 5%/PMMA CF, b) $\text{Cs}_2\text{SnCl}_6\text{:Te}$ 10%/PMMA CF and c) $\text{Cs}_2\text{SnCl}_6\text{:Te}$ 20%/PMMA CF.

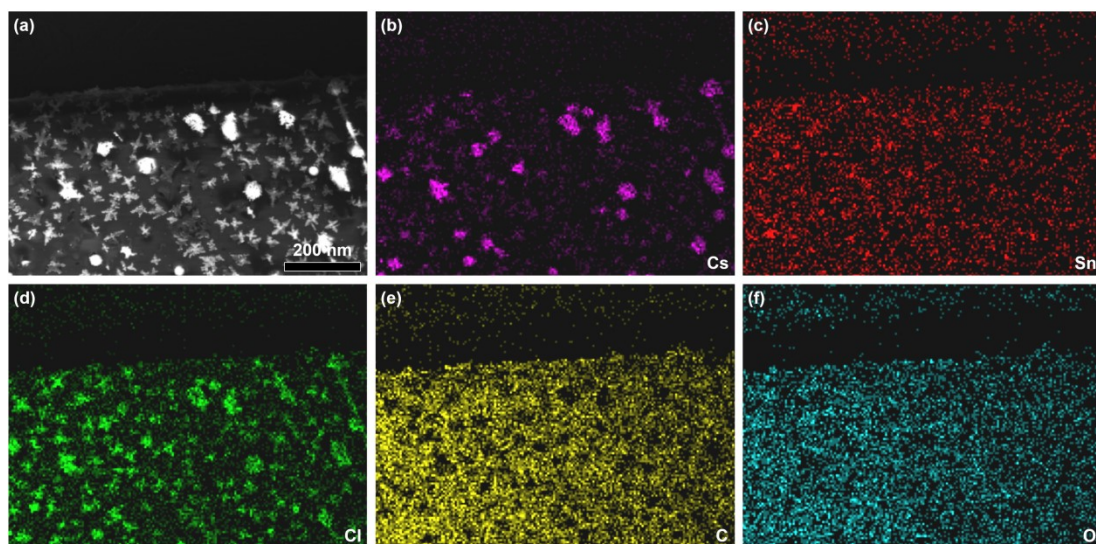


Figure S2. EDS mapping of $\text{Cs}_2\text{SnCl}_6/\text{PMMA}$ CF.

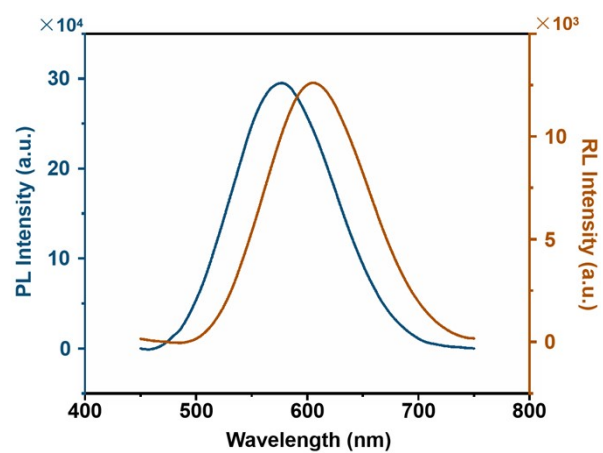


Figure S3. RL spectra at a dose rate of 200 nGy_{air}s⁻¹ and PL spectra of Cs₂SnCl₆:Te 15%/PMMA CFs.

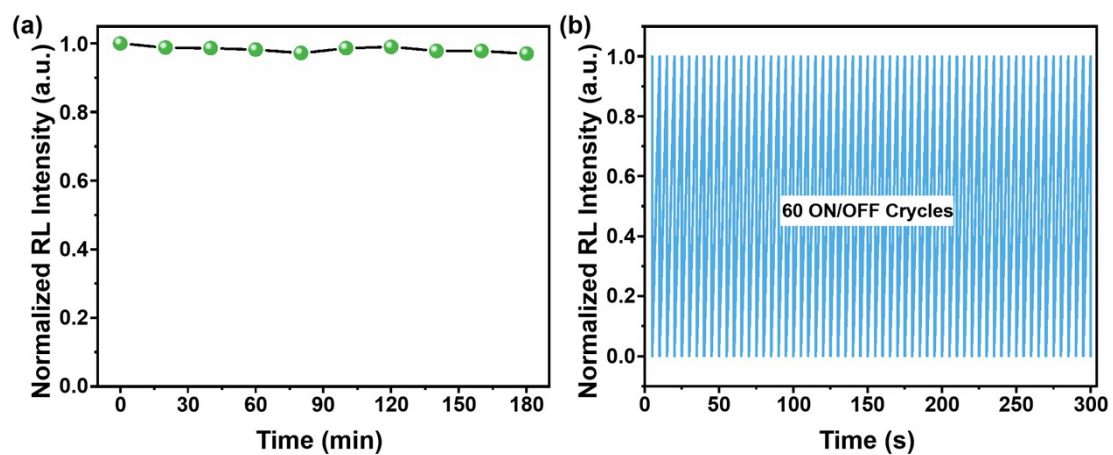


Figure S4. (a) Normalized RL spectra of $\text{Cs}_2\text{SnCl}_6\text{:Te}$ 15%/PMMA CFs under continuous X-ray irradiation. (b) RL intensities recorded for $\text{Cs}_2\text{SnCl}_6\text{:Te}$ 15%/PMMA CFs over continuous 60 on/off cycles. (dose rate: $10 \mu\text{Gyair}_s^{-1}$, tube voltage: 50 kV)

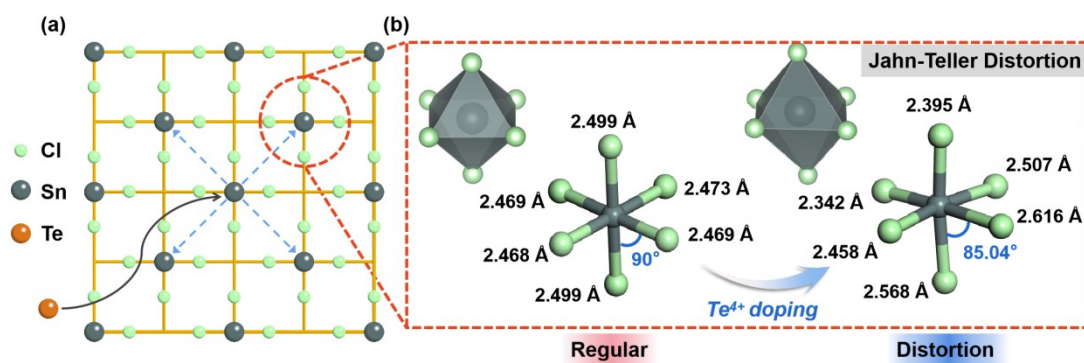


Figure S5. a) Cs_2SnCl_6 : Te^{4+} cell structure, in which Te^{4+} ion replaces Sn^{4+} ion. b) Jahn–Teller distortion: schematic diagrams of $[\text{SnCl}_6]^{2-}$ octahedra without doping (regular) and with doping (distortion).

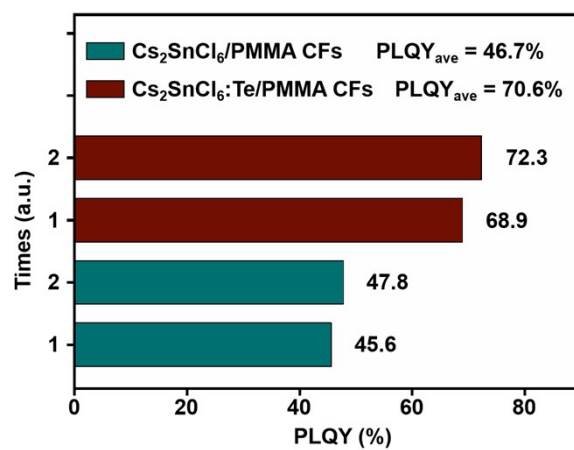


Figure S6. The PLQY value of $\text{Cs}_2\text{SnCl}_6/\text{PMMA CFs}$ and $\text{Cs}_2\text{SnCl}_6:\text{Te } 15\%/\text{PMMA CFs}$

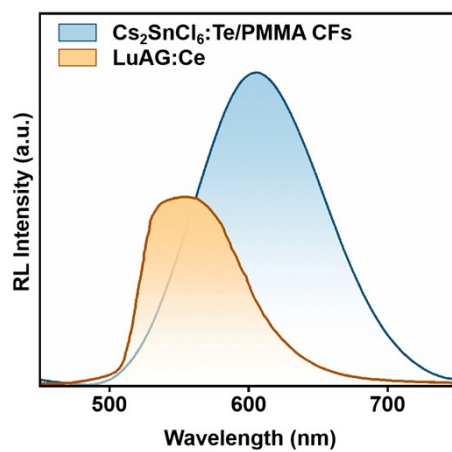


Figure S7. RL spectra of Cs₂SnCl₆:Te/PMMA CFs and LuAG:Ce(dose rate: 10 μGyair_s^{-1} , tube voltage: 50 kV)

Table S1 Bi-exponential fitting results of PL decays for Cs₂SnCl₆:Te/PMMA CFs with different Te content.

Sample	τ_1 (ns)	A ₁ (%)	τ_2 (ns)	A ₂ (%)	τ_{ave} (ns)
Cs ₂ SnCl ₆ :Te/PMMA-5%	83.5	76.5	1353.2	23.5	1140.2
Cs ₂ SnCl ₆ :Te/PMMA-10%	96.1	73	1597.5	27	1387.1
Cs ₂ SnCl ₆ :Te/PMMA-15%	129	49.9	1756.9	50.1	1620.4
Cs ₂ SnCl ₆ :Te/PMMA-20%	112	55.5	1562	44.5	1464.7

The decay trajectories of all samples can be fitted to the double exponential function Y(t) according to the following nonlinear least squares:

$$Y(t) = A_1 e^{-\frac{t}{\tau_1}} + A_2 e^{-\frac{t}{\tau_2}} \dots\dots(S1)$$

where A₁, A₂ are the contributions to the time-resolved emission decay lifetimes τ_1 , τ_2 , respectively.

The average lifetime of the sample (τ_{ave}) can be obtained from the following equation:

$$\tau_{ave} = \frac{A_1 \tau_1^2 + A_2 \tau_2^2}{A_1 \tau_1 + A_2 \tau_2} \dots\dots(S2)$$

Table S2 Nominal and actual Te/(Sn+Te) co-doping concentrations in Cs₂SnCl₆: Te micro-crystals. The nominal Te doping ratio was defined as the molar ratio of Te/(Sn+Te) in the precursor solution, and the actual Te/(Sn+Te) ratio was determined by ICP-MS

Sample	Te ⁴⁺ (g)	Te ⁴⁺ (mol)	Sn ⁴⁺ (g)	Sn ⁴⁺ (mol)	Te/Sn doping ratio (mol/mol)
Cs ₂ SnCl ₆	0	0	0.000046	3.87564E-7	0% / 100%
Cs ₂ SnCl ₆ :Te-5%	0.000003	2.3511E-8	0.000051	4.29691E-7	5.19% / 94.81%
Cs ₂ SnCl ₆ :Te-10%	0.000006	4.70219E-8	0.000042	3.53863E-7	11.73% / 88.27%
Cs ₂ SnCl ₆ :Te-15%	0.000007	5.48589E-8	0.000037	3.11736E-7	14.96% / 85.04%
Cs ₂ SnCl ₆ :Te-20%	0.00001	7.83699E-8	0.000035	2.94886E-7	20.99% / 79.01%

Table S3 Summary of X-ray scintillation performances of lead-free metal halides scintillation screens.

Sample	Attributes	Light yield (photons MeV ⁻¹)	Detection limit (nGy _{air} S ⁻¹)	Radiation stability	Ref.
(R/S-PPA) ₂ BiI ₅	Rigid	-	270	120 min 2.29 mGy _{air} S ⁻¹	[1]
Cs ₃ MnBr ₅ NC- embedded glass	Rigid	5200	787	60 min 5.775 mGy _{air} S ⁻¹	[2]
Cs ₄ Cd _{0.75} Mn _{0.25} Bi ₂ Cl ₁₂	Flexible	34450	183.6	180 min 10.53 mGy _{air} S ⁻¹	[3]
Cs ₃ TbCl ₆	Flexible	56800	149.65	240 min -	[4]
Cs ₃ Cu ₂ I ₅	Flexible	32,000	150.55	120 min 6.8 mGy _{air} S ⁻¹	[5]
Cs ₂ SnCl ₆ :Te/PMMA	Flexible	36000	112	180 min 10 μGy _{air} S ⁻¹	This work

Reference

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